

Program (Monday, 17 October 2022)

Time (Beijing)	Program		
8:10-8:30	Opening Ceremony, Lijun Liu		
Plenary lectures			
Session Chair: Lijun Liu			
8:30-9:00	Plenary lecture-1 by Koichi Kakimoto: Recent progress of numerical modeling in crystal growth process		
9:00-9:30	Plenary lecture-2 by Jeffrey J. Derby: Modeling high-pressure, high-temperature diamond crystal growth		
9:30-9:45	Group photo		
9:45-10:00	Coffee break		
Session 1: PV SILICON			
Session Chair: Thierry Duffar			
Session Co-Chair: Zaoyang Li			
Time (Beijing)	Authors	Title of Presentation	Affiliation
10:00-10:20	Tingting Du, Lu Cheng, Yongfei Wen, Chaoguang Zhang	The application of simulation in the field of mono-crystal silicon technology (Invited)	LONGi Green Energy Technology Co., Ltd
10:20-10:40	M. Srinivasan¹, P. Ramasamy¹, Noritaka Usami²	Growth of mc-Silicon ingot by DS Process: Computational Modeling, Experimental and Machine Learning Studies (Invited)	1.SSN College of Engineering 2.Nagoya University
10:40-10:55	Xin Liu¹, Hiroyuki Tanaka¹, Kentaro Kutsukake², and Noritaka	Multiscale modeling and optimization on the solidification and the grain evolution of the SMART ingot grown by DS-Si process	1.Nagoya University 2. RIKEN

	Usami ¹		
10:55-11:10	Thi-Hoai-Thu Nguyen ^{1,2} , Jyh-Chen Chen ¹ , Chun-Hsien Li ¹	Controlling heat and oxygen transport by heater power levels and double-partition depths during CCz silicon crystal growth	1.National Central University 2.Nong Lam University
11:10-11:25	G. Aravindan , M. Srinivasan, P. Ramasamy	Numerical Investigation of cone shape grooved DS furnace block to improve the mc-Si ingot quality	Sri Sivasubramaniya Nadar College of Engineering
11:25-11:40	Wenjia Su, Jiaqi Li, Jiulong Li, Zhicheng Guan, Zhen Zhang	Numerical study on the horizontal position of water-cooling jacket of Czochralski monocrystalline silicon	Jiangsu University
11:40-11:55	P. Karuppasamy, A. Suganraj, M. Bharathwaj, P. Periyannan, N. Balamurugan, M. Srinivasan, P. Ramasamy	Improving Convexity on Melt-Crystal Interface Shape on the Directional Solidification Process	Sri Sivasubramaniya Nadar College of Engineering
11:55-12:15	Alexandra Popescu, Daniel Vizman	Particularities of the thermal and oxygen concentration instabilities in a Czochralski process for solar silicon growth(Invited)	West University of Timisoara
12:15-14:00	Break		

Session 2: Silicon semiconductor

Session Chair: Noritaka Usami

Session Co-Chair: Kentaro Kutsukake

Time (Beijing)	Authors	Title of Presentation	Affiliation
14:00-14:20	Oleg Weinstein, Simon Brandon	Revisiting some questions regarding the interplay between capillarity, growth kinetics and heat transfer in relation to the geometry of crystals grown via the Czochralski method (Invited)	Technion – Israel Institute of Technology
14:20-14:40	Chunmei Wu , Ruiqi Huang, Xiyuan Xue, Lan Peng, Yourong Li	Effect of deformed free surface on the pattern transition and evolution of thermocapillary flow during Czochralski crystal growth (Invited)	Chongqing University

14:40-15:00	K. Zaidat¹, S. Al-Radi^{1,2}, H. Abouchi², Fl. Baltaretu³, X. Han¹, M. Al-Radi^{1,2}, C. Garnier², G. Hasan², R. Ernst², A. Nehari⁴, K. Lebbou⁴ and A. Kharicha⁵	Modelling of innovative cold crucible for single crystal growth (Invited)	1.Univ. Grenoble Alpes, SIMAP 2.CNRS, SIMAP 3.Technical University of Civil Engineering Bucharest 4. Université de Lyon 5 Christian-Doppler Laboratory for Metallurgical Applications of Magnetohydrodynamics
15:00-15:15	Roman Rolinsky, Fran ois Dupret	Comparison of FLET method for numerical modeling of a large CZ system with horizontal DC magnetic field with full 3D simulations and experimental measurements	FEMAG S.A.
15:15-15:30	Weichao Huang, Jiahao Li, Ding Liu	Study on inverse heat transfer at the solid-liquid interface of Czochralski silicon single crystal based on sequential function specification method	Xi'an University of Technology
15:30-15:45	Songsong Chen ¹ , Wenkai Liu ^{1,2} , Zhongying Xue ¹ , Xing Wei ^{1,3}	Numerical simulation of industrial 300 mm Czochralski single silicon growth with transverse magnetic field	1.Shanghai Institute of Microsystem and Information Technology 2.ShanghaiTech University 3.Zing Semiconductor Corporation
15:45-16:00	Y. Li ^{1,2} , A.D. Smirnov ³ , R. Qin ^{1,2} , Z. Zhang ⁴ , Z. Shan ^{1,2} , H. Fu ⁴	Extended investigation of an abrupt crystal diameter change during Czochralski silicon growth in transverse magnetic field	1.GRINM National Engineering Research Center for Integrated Circuit Key Materials 2.GRINM Semiconductor Materials Co., Ltd. 3.Semiconductor Technology Research d.o.o. Beograd 4. Suzhou STR Software Technology

			Co., Ltd.
16:00-16:15		Coffee break	
Session 3: Algorithm method /Software development			
Session Chair: Natasha Dropka			
Session Co-Chair: Kaspars Dadzis			
Time (Beijing)	Authors	Title of Presentation	Affiliation
16:15-16:35	Kentaro Kutsukake	Applications of machine learning to crystal growth research (Invited)	RIKEN
16:35-16:55	Kaspars Dadzis , Arved Enders-Seidlitz, Iason Tsapkinis	Open source models for multiphysical simulation of crystal growth (Invited)	Leibniz-Institut für Kristallzüchtung (IKZ)
16:55-17:10	Andrey Vorob'ev , Vladimir Kalaev , Kirill Mazaev	Chemical model of sapphire crystal growth by Ky technique	Soft-Impact Ltd.
17:10-17:25	Heyu Lu, Songzhe Xu, Ling Shi, Chaoyue Chen, Jiang Wang, Zhongming Ren	A multi-scale numerical study based on phase field method for microstructure of Ni-based superalloys in additive manufacturing	Shanghai University
17:25-17:40	Ling Shi, Songzhe Xu, Jingjing Li, Chaoyue Chen, Jiang Wang, Zhongming Ren	A phase field based computational framework for simulating microstructure growth under magnetic field in alloy solidification	Shanghai University
17:40-17:55	Xin Zhang ¹ , Wenliang Lu ² , Zun Liang ¹ , Yashen Wang ¹ , Songtai Lv ¹ , Hongtao Liang ¹ , Brian B. Laird ³ , Yang Yang ¹	Characterization of the local collective dynamics at the crystal-melt interface	1. East China Normal University 2. Changzhou Institute of Technology 3. University of Kansas
17:55-18:10	Shuyan Shi, Ding Liu, Zhiran Huo	Simulation of thermoelastic coupling in silicon single crystal growth based on alternate two-stage physical-informed neural	Xi'an University of Technology

		network	
18:30-20:30		Banquet	

Program (Tuesday, 18 October 2022)

Session 4: Wide bandgap semiconductors (I)			
Session Chair: Koichi Kakimoto			
Session Co-Chair: Wenjia Su			
Time (Beijing)	Authors	Title of Presentation	Affiliation
8:10-8:30	Koichi Kakimoto , Isao Takahashi, Taketoshi Tomida, Kei Kamada, Yongzhao YAO, Satoshi Nakano, Akira Yoshikawa	3D calculation studies of dislocation density in a β -Ga ₂ O ₃ crystal grown by vertical Bridgman method(Invited)	1.Tohoku University 2.C&A Co. 3.Japan Fine Ceramics Center 4. Kyushu University
8:30-8:50	Liang Wu	Multiscale modeling and simulation of AlN growth: from marcoscale to nanoscale(Invited)	Ultratrend Technologies Inc.
8:50-9:05	Dan Wu ^{1,2} , Ning Xia ² , Keke Ma ² , Jiabin Wang ² , Cheng Li ^{1,2} , Hui Zhang ^{1,2}	Numerical simulation of β -Ga ₂ O ₃ seeds with different transparency in Czochralski system	1.Zhejiang University 2.ZJU-Hangzhou Global Scientific and Technological Innovation Center
9:05-9:20	Wenjia Su, Zhicheng Guan, Jiulong Li, Zhen Zhang, Jiaqi Li, Wenjia Su	Numerical study on the effects of argon gas guidance system on the growth of β -Ga ₂ O ₃ by Czochralski method	Jiangsu University
9:20-9:35	Pengfei Han, Bing Gao, Botao Song, Yue Yu, Xia Tang, Botao Liu	Optimization of Ammonothermal GaN Growth Based on Numerical Simulation and Machine Learning	Wuhan University
9:35-9:50	Fuchang Li, Lei He, Chaoyang Yan, Xiaofang Qi, Wencheng Ma, Jianli Chen, Yongkuan Xu, Zhanggui Hu	Effects of crystal and crucible rotation on the carbon distribution during solution growth of SiC single crystal	Tianjin University of Technology

9:50-10:05

Coffee break

Session 5: Wide bandgap semiconductors (II)

Session Chair: Liang Wu

Session Co-Chair: Yifan Dang

Time (Beijing)	Authors	Title of Presentation	Affiliation
10:05-10:25	Wensen Ai, Xuejiang Chen	Nucleation preference of trimers during SiC (0001) surface epitaxial growth under low coverage(Invited)	Xi'an Jiaotong University
10:25-10:40	Yifan Dang ¹ , Xinbo Liu ¹ , Yuma Fukami ¹ , Shuyang Ma ¹ , Can Zhu ¹ , Shunta Harada ¹ , Miho Tagawa ¹ , Toru Ujihara ^{1,2}	Simulation of Macrosteps Development for Solution Growth of SiC	1.Nagoya University 2.GaN-OIL, AIST
10:40-10:55	Huiqin Zhou, Yifan Dang , Yuma Fukami , Hisaki Takemoto, Shunta Harada, Miho Tagawa, Toru Ujihara	Phase-Field Simulation of Inclusion Defect Generation in SiC Solution Crystal Growth Method	Nagoya University
10:55-11:10	Rong Wang, Jiajun Li, Xiaodong Pi, Deren Yang	Modeling dislocation behaviors during the nitrogen doping of 4H silicon carbide	Zhejiang University
11:10-11:25	Xuefeng Han, Deren Yang, Xiaodong Pi	Numerical analysis of species transport in the PVT-SiC process	Zhejiang University
11:25-11:40	Binjie Xu, Xuefeng Han, Deren Yang, Xiaodong Pi	Optimization of the thermal field of 8-inch SiC crystal growth by PVT method with “3 separation heater method”	1.ZJU-Hangzhou Global Scientific and Technological Innovation Center 2.Zhejiang University
11:40-11:55	Chun-Hung Chen, Cheng-Kai Xu	Effects of graphite cover on heat and flow transport during PVT-SiC process	Xinxin Semiconductor (Group) Co., Ltd.
11:55-12:15	C. Kranert ¹ , M. Hainke ^{1,2} ,	Modeling the growth of ultrawide bandgap materials(Invited)	1.Fraunhofer IISB

	J. Friedrich ¹		2.Ostbayerische Technische Hochschule (OTH) Amberg-Weiden
12:15-14:00		Break	
Session 6: Novel Topics			
Session Chair: Wolfram Miller			
Session Co-Chair: Chunmei Wu			
Time (Beijing)	Authors	Title of Presentation	Affiliation
14:00-14:20	H. Koch ^{1*} , S. Hürner ¹ , T. Jauss ² , T. Sorgenfrei ² , M. Hainke ^{1,3} , C. Kranert ¹ , J. Friedrich¹	Modeling of solidification processes under consideration of particle transport in the melt for terrestrial and microgravity conditions(Invited)	1.Fraunhofer IISB 2.University of Freiburg 3.Ostbayerische Technische Hochschule (OTH) Amberg-Weiden
14:20-14:40	Agneta M. Balint, Stefan Balint	Inequalities for shaped crystal growth by pulling down method(Invited)	West University of Timisoara
14:40-14:55	Mingwen Chen, Zidong Wang	The Evolution and Morphological Stability of a Particle in a Binary Alloy Melt	University of Science and Technology Beijing
14:55-15:10	Qinghua Yu, Fuwu Yan, Yuxiang Peng, Rui Ao	Numerical simulation of CO ₂ hydrate crystal growth for direct-contact cold energy storage	Wuhan University of Technology
15:10-15:25	Qin Shu, Jia-Jia Yu, Chun-Mei Wu, You-Rong Li	Numerical simulations of thermocapillary-buoyancy convection in a side-heated annular pool with different depths	Chongqing University
15:25-15:40	Jiayu Dong, Simin Wang	Ultrasound enhancement of p-xylene crystallization characteristics and regulation mechanism of experimental research	Xi'an Jiaotong University
15:40-15:55	Coffee break		

Session 7: Vapor and solution growth			
Session Chair: J. Friedrich			
Session Co-Chair: Qinghua Yu			
Time (Beijing)	Authors	Title of Presentation	Affiliation
15:55-16:15	Wolfram Miller ¹ , Tobias Schulz ¹ , Liverios Lymperakis ² , Andrew Klump ¹ , Martin Albrecht ¹	Kinetic Monte Carlo Simulations of AlN and AlGaN epitaxy on AlN(0001) (Invited)	1.Leibniz-Institut für Kristallzüchtung (IKZ) 2.University of Crete
16:15-16:35	Roberto Bergamaschini , Francesco Montalenti, Leo Miglio	Continuum modeling of 3D semiconductor epitaxy: thermodynamic and kinetic driving forces behind morphological and compositional evolution (Invited)	University of Milano-Bicocca
16:35-16:50	Ta-Shun Chou, Saud Bin Anooz, Raimund Grüneberg, Natasha Dropka, et al	Machine Learning-assisted Homoepitaxial Growth of (100) β -Ga ₂ O ₃ by MOVPE	Leibniz-Institut für Kristallzüchtung (IKZ)
16:50-17:05	Ba-Phuoc Le ¹ , Wei-Jie Lin ¹ , Jyh-Chen Chen ¹ , Chieh Hu ² , Chun-Chin Tu ² , Liang-Chin Chen ²	Effect of side inlet on deposition rate near wafer edge during APCVD deposition	1.National Central University 2.Global Wafer Co., Ltd
17:05-17:20	Hang Liu ¹ , Mingwei Li ² , Duanyang Chen ^{3,4} , Hongji Qi ^{3,4} , Shuxian Chen ¹ , Yi Xiao ¹ , Yue Hu ¹ , Binbin Lin ¹	Numerical simulation of thermal stress during ADP crystal growth by solution circulating method	1.Civil Aviation Flight University of China 2.Chongqing University 3.Shanghai Institute of Optics and Fine Mechanics, CAS 4.Hangzhou Institute of Optics and Fine Mechanics
17:20-17:35	Vladimir Artemyev, Andrey Smirnov	CVDSim3D as the 3D tool for simulation of Global Heat	Semiconductor Technology

		Transfer in AMAT Centura Silicon epitaxy process	Research d.o.o. Beograd (STR Beograd)
17:35-18:30	Session 8: Poster Session		
Poster NO.	Authors	Title of Poster	Affiliation
P1	Xingchun Xu, Jiecai Han, Jiaqi Zhu	Adaptive phase-field-based lattice Boltzmann simulation for three-dimensional dendrite growth	Harbin Institute of Technology
P2	Ling Shi, Songzhe Xu, Jingjing Li, Heyu Lu, Chaoyue Chen, Jiang Wang, Zhongming Ren	Modification and application of virtual submesh cellular automata method in additive manufacturing	Shanghai University
P3	Bangjie Geng, Hao Fu	New development in modeling of PVT SiC bulk crystal growth	Suzhou STR Software Technology Co. Ltd.
P4	Chunhui Tian, Shuang Liu, Shenglan Wu, Jiacheng Li, Dejun Chen, Yong Liu, Zhiyong Zhong	The Fluorescence Transformation Efficiency Research of the Hexagonal microcrystalline column model of CsI(Tl) Film	University of Electronic Science and Technology of China
P5	Fuman Jiang ¹ , Zhongying Xue ¹ , Xing Wei ^{1,2}	Modeling and Simulation of Silicon Epitaxy Growth in the Atmospheric Chemical Vapour Deposition Reactor	1.Shanghai Institute of Microsystem and Information Technology 2.Zing Semiconductor Corporation
P6	Yashen Wang, Zun Liang, Xin Zhang, Wenliang Lu, Zhiyong Yu, Xiangming Ma, Hongtao Liang, Yang Yang	A few progress in predicting solidification kinetics using the time-dependent Ginzburg-Landau solidification theory	East China Normal University
P7	Wenliang Lu ¹ , Hongtao Liang ² , Xiangming Ma ² , Zifeng Yuan ² , Xin Zhang ² , Zun Liang ² , Yang Yang ²	Atomistic Simulation Study of the Crystal-Melt Interface Excess Stresses	1.Changzhou Institute of Technology 2.East China Normal University
P8	Liangyu Zhou, Zaoyang Li, Lijun	Bubble behaviors at the solid-melt interface in crystal growth	Xi'an Jiaotong University

	Liu		
P9	Jinwen Shi, Binjiang Zhai, Yazhou Zhang, Cheng Cheng	Bulk/surface engineering of g-C ₃ N ₄ for high-efficiency photocatalytic H ₂ production	Xi'an Jiaotong University
P10	Yuanchun He, Wanyuan Shi	Three-dimensional Nonlinear Thermocapillary Convection of Low Prandtl Number Fluid in Annular Pools	Chongqing University
P11	Dongming Mo ¹ , Qin Shu ² , Jiajia Yu ² , Chunmei Wu ² , Yourong Li ²	Prandtl number dependence of instability of thermocapillary convection in an annular pool with a heated inner cylinder	1.Chongqing Industry Polytechnic College 2.Chongqing University
P12	Yong Liu ¹ , Liangqi Zhang ¹ , Hao Liu ² , Yao Xiao ¹ , Yue Wang ¹ , Hao Li ¹ , Zhong Zeng ¹	Effect of radius ratio on the instability of the mixed convection in the Czochralski model	1.Chongqing University 2.Chongqing Jiaotong University
P13	Xiaofang Qi ^{1,2,3} , Junlei Wang ³ , Wencheng Ma ¹	Effects of water-cooled jacket on the oxygen distribution during the Czochralski silicon crystal growth process	1.Tianjin University of Technology 2.Jiangsu University 3.Jiangsu Huantai Group Co., Ltd.
P14	Shanshan Tang ¹ , Jinping Luo ¹ , Chuanbo Chang ^{1,2} , Quanzhi Wang ³ , Lijun Liu ¹	A new form of impurity cluster in casting quasi-single crystalline silicon	1.Xi'an Jiaotong University 2.Golden Solar Silicon Industry Technologie (XuZhou) Co., Ltd. 3.Yanshan University
P15	Chuanbo Chang ^{1,2} , Shanshan Tang ¹ , Jiancheng Li ¹ , Changzhen Wang ¹ , Zaoyang Li ¹ , Lijun Liu ¹	Improvement of the thermal field to reduce edge dislocation of cast monocrystalline silicon	1.Xi'an Jiaotong University 2.Golden Solar Silicon Industry Technologie (XuZhou) Co., Ltd.
P16	Jiancheng Li, Zaoyang Li, Lijun Liu, Yuqi Jin, Changzhen Wang	Effects of melt depth on oxygen transport in silicon crystal growth with continuous-feeding Czochralski method	Xi'an Jiaotong University
P17	Jiancheng Li ¹ , Shanshan Tang ¹ , Chuanbo Chang ^{1,2} , Changzhen Wang ¹ , Zaoyang Li ¹ , Lijun Liu ¹	Study on the thermal field uniformity in the cast monocrystalline silicon furnace	1.Xi'an Jiaotong University 2.Golden Solar Silicon Industry Technologie (XuZhou) Co., Ltd.

P18	Changzhen Wang ¹ , Jiancheng Li ¹ , Shanshan Tang ¹ , Chuanbo Chang ^{1,2} , Zaoyang Li ¹ , Lijun Liu ¹	Control of the seed crystal melting interface for the growth of monocrystalline silicon ingots	1.Xi'an Jiaotong University 2.Golden Solar Silicon Industry Technologie (XuZhou) Co., Ltd.
P19	Yuqi Jin ¹ , Zaoyang Li ¹ , Jiancheng Li ¹ , Changzhen Wang ¹ , Zhongying Xue ² , Lijun Liu ¹	Numerical study of 12 inch silicon crystal growth by continuous-feeding Czochralski	1.Xi'an Jiaotong University 2.Shanghai Institute of Microsystem and Information Technology
P20	Wenjia Su, Zhen Zhang, Jilong Li, Zhicheng Guan, Jiaqi Li	Numerical study on the effects of inner crucible window heights on the growth of single-crystalline silicon in a continuous Czochralski process	Jiangsu University
P21	Chun-Hung Chen	Effects of CUSP magnetic field on heat and oxygen transport during continues-feeding CZ process	Xinxin Semiconductor (Group) Co., Ltd.
P22	Wenkai Liu ^{1,2} , Songsong Chen ¹ , Zhongying Xue ¹ , Xing Wei ^{1,3} , Yuehui Yu ¹	Crystallization interface correction in simulation of Czochralski crystal growth with an asymmetric magnetic field	1.Shanghai Institute of Microsystem and Information Technology 2.ShanghaiTech University 3.Zing Semiconductor Corporation
P23	Chun-Hung Chen, Xiao-Xiao Liu	Effects of High-strength superconducting horizontal magnetic field on heat and flow transport by 3D simulation and experiments	Xinxin Semiconductor (Group) Co., Ltd.
P24	Lei He, Fuchang Li, Zhaoyang Yan, Xiaofang Qi, Wencheng Ma, Jianli Chen, Yongkuan Xu, Zhanggui Hu	Thermal field design of resistance heated SiC crystal growth furnace by solution growth	Tianjin University of Technology
P25	Yuzhe Bu ^{1,2} , Qinglin Sai ¹ , Hongji Qi ^{1,3}	Stability of interfacial thermal balance in thick β -Ga ₂ O ₃ crystal growth by EFG	1.Shanghai Institute of Optics and Fine Mechanics 2.University of Chinese Academy of Sciences 3.Hangzhou Institute of Optics and

			Fine Mechanics
P26	Qian Xia, Xuejiang Chen, Wensen Ai	Study on three-dimensional critical nucleation on a planar substrate of SiC crystal	Xi'an Jiaotong University
P27	Zaoyang Li, Ruijing Shi, Xingyu Xu, Fan Zhu, Lijun Liu	Numerical study of die shape for the β -Ga ₂ O ₃ crystal growth by EFG	Xi'an Jiaotong University
P28	D. Shobana Priyanka ¹ , J. B. Sudharsan ² , M. Srinivasan ¹ , P. Ramasamy ¹ , M. K. Choudhary ³ , P. Ravindran ³	A new half metallic quaternary Heusler alloys for spin polarized device application and waste heat recovery treatment: Material computation	1.SSN College of Engineering 2.Chennai Institute of Technology 3.Central University of Tamil Nadu
P29	C. Elavarasi, S. Mugundan	Growth and Hirshfeld Surface Analysis of Imidazolium Fumarate (IMF) Single Crystal and DFT Computational Calculations for Third harmonic Generation	Sri Vijay Vidyalaya College of Arts and Science
P30	K. Clinton Brito, D. Shobana Priyanka, M. Srinivasan, P. Ramasamy	The computational investigation of Co based quaternary Heusler alloys compatible for spin flip device and thermoelectric applications	SSN College of Engineering
P31	T. Keerthivasan, M. Srinivasan, P. Ramaswamy	Numerical Investigation of Partial Replacement of Graphite Supporter to grow mc-Si on DS Furnace	SSN College of Engineering
P32	Sugunraj Sekar, Aravindan Gurusamy, Srinivasan Manikkam, Ramasamy Perumalsamy	Modification of heat exchanger block to enhance the quality of mc-Si ingot grown by DS process for solar cell application	Sri Sivasubramaniya Nadar College of Engineering
P33	M. Bharathwaj, S. Sugunraj, M. Srinivasan, P. Karuppasamy, P. Ramasamy	Numerical investigation of non-metal impurities on the DS grown mc-silicon ingot: Effect of argon flow rate	Sri Sivasubramaniya Nadar College of Engineering
P34	Yuan Li ¹ , Xuejiang Chen ² , Wensen Ai ²	Kinetic Monte Carlo simulation study of the early stages of epitaxial SiC (0001) growth	1.Qinghai Minzu University 2.Xi'an Jiaotong University
P35	Xin Wen ¹ , Nuofu Chen ^{1,3} , Yu Zhang ¹ ,	Effects of surface size and shape of polycrystalline powder on	1.North China Electric Power

	Wenrui Hu ^{3,4} , Jikun Chen ²	the silicon carbide crystal growth by PVT method	University 2.University of Science and Technology Beijin 3.Yunnan Lincang Xinyuan Germanium Industry Co, Ltd. 4.Chinese Academy of Sciences
P36	Qihang Li, Jinping Luo, Lijun Liu	Study on factors of large area graphene obtained by chemical vapor deposition	Xi'an Jiaotong University
P37	Shaohua Du ^{1,2} , Lijun Liu ²	Numerical investigation of Polysilicon Particle Growth in a Fluidized Bed Reactor	Xi'an Jiaotong University
P38	Xia Tang ² , Botao Liu ¹ , Yue Yu ¹ , Botao Song ¹ , Pengfei Han ¹ , Sheng Liu ¹ , Bing Gao ¹	Study on the spiral growth mechanism of gallium oxide by quantitative model	1.Wuhan University 2.Leibniz institute for crystal growth
P39	Junling Ding ¹ , Yuqing Li ¹ , Lijun Liu ²	Effect of cusp magnetic field on the turbulent melt flow and heat transfer during 300mm Czochralski silicon crystal growth	1.East China Jiaotong University 2.Xi'an Jiaotong University
P40	Teng-Hui You, Xiang-Cao Li, Xin Ju	Study on coating exfoliation damage of KDP component under laser irradiation by surface analysis	University of Science and Technology Beijing
P41	Jing Zhang, Ding Liu, Ruixin Lv, Xiaojun Chang	Study on Diameter Control of Czochralski Silicon in Shouldering	Xi'an University of Technology
20:00-21:00	Int. Advisory committee meeting(online)		

Program (Wednesday, 19 October 2022)

Session 9: Melt growth			
Session Chair: Hui Zhang			
Session Co-Chair: Zhixin Li			
Time (Beijing)	Authors	Title of Presentation	Affiliation
8:10-8:30	Thierry Duffar , Lingling Xuan	Modelling dopant valence in ionic crystal growth: the Ti:Al ₂ O ₃ case (Invited)	Univ. Grenoble Alpes
8:30-8:45	Zhixin Li ¹ , Andrey Smirnov ²	Computer modeling increases pulling rate and productivity of Czochralski pullers in PV Si crystal growth (Invited)	1.Linton Technologies Group 2.STR Group - Soft Impact, Ltd.
8:45-9:00	Zaoyang Li ¹ , Liangyu Zhou ¹ , Niefeng Sun ² , Huimin Shao ² , Lijie Fu ² , Shujie Wang ² , Yue Wang ³ , Lijun Liu ¹	Shielding of traveling magnetic field for the crystal growth with low electrical conductivity	1.Xi'an Jiaotong University 2.Hebei Semiconductor Research Institute 3.Engreat Precision Machine Co. Ltd.
9:00-9:15	Pengfei Wang ¹ , Hui Zhang ² , Lili Zheng ² , Liangbi Su ¹	Process Control and Optimization of Large-Size CaF ₂ Crystal Growth System	1.Shanghai Institute of Ceramics, CAS 2.Tsinghua University
9:15-9:30	Hao Li, Zhong Zeng, Liangqi Zhang, Yue Wang, Yong Liu	The effect of Rotating Magnetic Field on thermocapillary liquid bridges between unequal ends	Chongqing University
9:30-9:45	Xiaofang Qi, Hang Yu, Wencheng Ma, Yongkuan Xu, Zhanggui Hu	Effect of internal radiation on thermal stress during Ti:sapphire crystal growth process by heat exchanger method	Tianjin University of Technology
9:45-10:00	Tai Li	Numerical simulation and experimental study of the effect of pulling rate on the shape of	Kunming University of Science and Technology

		solid-liquid interfaces and silicon rod stresses during the growth of Czochralski single-crystal silicon				
10:00-10:15	Coffee break					
Session 10: Micro and meso scale simulation						
Session Chair: Chung-Wen Lan						
Session Co-Chair: Jinping Luo						
Time (Beijing)	Authors	Title of Presentation	Affiliation			
10:15-10:35	Jinping Luo ¹ , Chenyang Zhou ¹ , Yunjie Cheng ¹ , Qihang Li ¹ , Lijun Liu ¹ , Jack F. Douglas ² , Talid Sinno³	Impact of configurational entropy on point defect thermodynamics in silicon(Invited)	1.Xi'an Jiaotong University 2.National Institute of Standards and Technology 3.University of Pennsylvania			
10:35-10:55	Yang Yang	Kinetics of Crystallization and Orientational Ordering in Dipolar Particle Systems (Invited)	East China Normal University			
10:55-11:10	Jinping Luo, Chenyang Zhou, Qihang Li, Lijun Liu	Atomic transport properties of silicon melt	Xi'an Jiaotong University			
11:10-11:25	Thamanna Begum. K, Punithavelan. N, Srinivasan. M	Investigation of the structural, electronic, magnetic and thermoelectric properties of Semi Heusler alloys ZrMnX (X = As, Sb, Te): A DFT based simulation	1.Vellore institute of technology 2.SSN college of engineering			
11:25-11:40	Zun Liang, Yashen Wang, Xin Zhang, Wenliang Lu, Zhiyong Yu, Xiangming Ma, Hongtao Liang, Yang Yang	Understanding the solidification kinetic anisotropy via BCC crystal–melt interfaces	East China Normal University			
11:40-11:55	Abdullah Alateeqi ^{1,2} , Talid Sinno ¹	Computational Study of Silicon Non-	1.University of Pennsylvania			

		Classical Homogeneous Nucleation	2.Kuwait University
11:55-12:10		Closing Ceremony, Lijun liu	
12:10-14:00		Break	
14:00		Visit LONGi	
18:00		End of IWMCG-10	